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Nickel-catalyzed regiodivergent sulfonylarylation of 1,3-enynes to access allenes and dienes†

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The radical-mediated difunctionalization of 1,3-enynes facilitates rapid access to structurally diverse allenes and dienes. Whereas, owing to the existence of multiple active sites in conjugated 1,3-enynes, regulating selectivity in difunctionalized addition *via* a single transition-metal-catalyzed radical tandem process remains elusive. Herein, we disclose an intriguing protocol of substrate-controlled nickel-catalyzed regiodivergent sulfonylarylation of 1,3-enynes with the assistance of sulfonyl chlorides and arylboronic acids. This valuable synthetic utility respectively delivers a series of highly functionalized and synthetically challenging allenyl sulfones and dienyl sulfones from fine-tuned 1,3-enynes by one step, which provides a facile approach for complex sulfone-containing drug molecules synthesis.

Introduction

Molecular scaffolds containing sulfones are important structures in many areas of chemical research from agrochemicals to pharmaceuticals (Fig. 1a).[1] Hence considerable efforts have been devoted to the efficient incorporation of sulfonyl motifs into organic molecules.[2] Among the different kinds of sulfonyl sources, commercially available sulfonyl chlorides have emerged as a particularly attractive candidate due to their abundance, low toxicity, stable physiochemical properties and cost efficiency.[2e] In this context, sulfonyl chloride has continually been employed as a radical precursor in photo-catalytic sulfonylation[3] and transition-metal-catalyzed C–H activated sulfonylation[4] during the past decades (Fig. 1b, left). In contrast, only limited progress has been made in transition-metal-catalyzed multicomponent radical sulfonation of unsaturated C–C bonds with sulfonyl chlorides. For example, nickel-catalyzed intermolecular sulfonylarylation of alkynes with sulfonyl chlorides and arylboronic acids has been established by the group of Nevado in 2017.[5] Recently, Li and co-workers have discovered a sulfonylarylation of alkenes or 1,3-dienes employing sulfonyl chlorides and organozinc pivalates as reaction partners through a cobalt-catalyzed radical relay pathway (Fig. 1b, right).[6] To date, reported advances have mainly focused on the sulfonylarylations of conventional alkynes or alkenes frameworks, thus the related multicomponent sulfonylarylation[7] for introducing a sulfonyl group into

unactivated 1,3-enynes[8] with sulfonyl chloride by a single transition-metal-catalyzed radical procedure still deserves further investigation.

All the time, the radical-mediated 1,4-difunctionalization of 1,3-enynes is recognized as one of most straightforward strategy to introduce two functional groups simultaneously towards the synthesis of polysubstituted allenes.[9] Several impressive approaches for the 1,4-difunctionalization of conjugated 1,3-enynes have well been developed through a radical pathway in recent years (Fig. 1c, left).[10] Compared with 1,4-difunctionalization, radical 3,4-addition research of 1,3-enynes is still in its infancy, and there are only a handful of significant reports for generating multiple functionalized 1,3-dienes (Fig. 1c, right).[11] In 2021, dual photoredox/nickel-catalyzed regiodivergent sulfonylarylation of 1,3-enynes has been reported by the group of Lu.[12] Despite such breakthroughs, it is undeniable that the selective construction of allenes or dienes from fine-tuned 1,3-enynes[13] through a 1,4-addition or 3,4-addition process remains a formidable challenge under a simpler catalytic system.

Inspired by these pioneering works and our interest in 1,3-enynes radical addition,[14] we validated the possibility of regiodivergent difunctionalization of 1,3-enynes by switching the positions of the triple bonds in the substrates to realize the selective preparation of allenyl sulfones and dienyl sulfones using sulfonyl chloride as careful selection of radical precursor with the help of the unique catalytic reactivity of the nickel complex.[15] The following crucial challenges need to be overcome: (i) controlling addition site in difunctionalization of such more intricate π-system substrate; (ii) compatibility of radical and reaction partners; (iii) direct competitive sulfonylarylation between sulfonyl source and arylnucleophile. With these clues in mind, we describe a novel strategy to achieve a substrate-controlled regiodivergent radical sulfonylarylation of 1,3-

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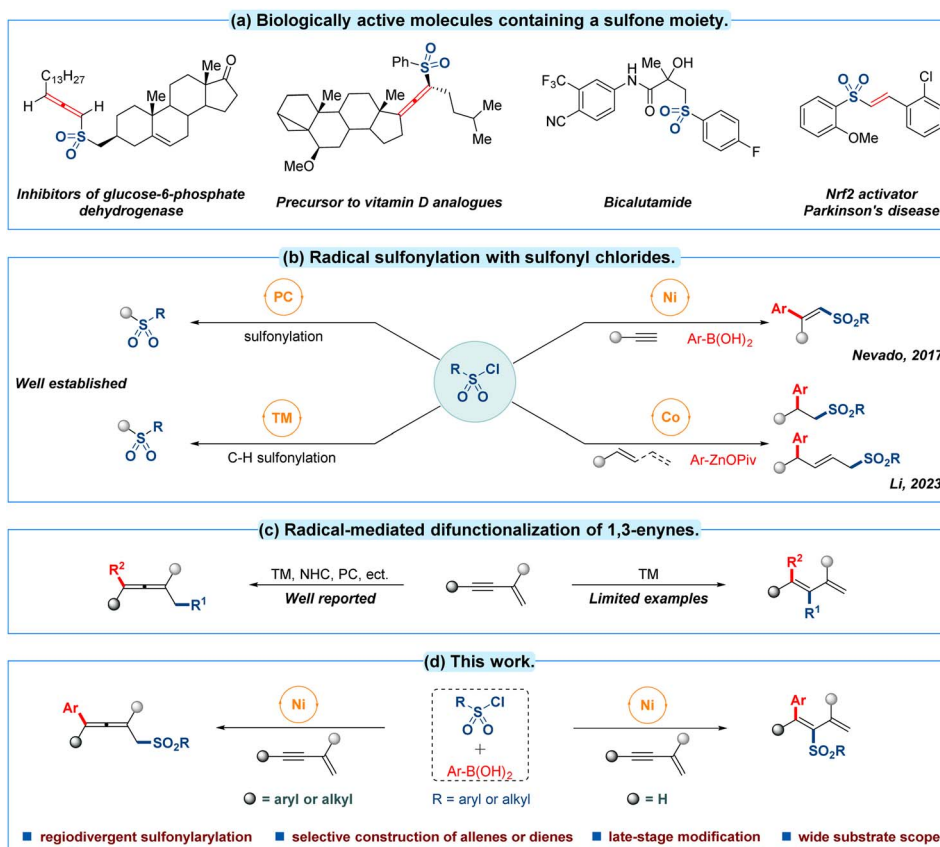
Fig. 1 (a) Biologically active molecules containing a sulfone moiety. (b) Radical sulfonylation with sulfonyl chlorides. (c) Radical-mediated difunctionalization of 1,3-enynes. (d) This work: nickel-catalyzed regiodivergent sulfonylarylation of 1,3-enynes with sulfonyl chlorides.

Table 1 Optimization of reaction conditions[a]

Entry	Ni-catalyst	Ligand	Solvent	Yield of 4
1	Ni(PPh$_3$)$_2$Cl$_2$	L1	Toluene	4%
2	Ni(PPh$_3$)$_2$Cl$_2$	L2–4	Toluene	4–21%
3	Ni(PPh$_3$)$_2$Cl$_2$	L5	Toluene	25%
4	Ni(PPh$_3$)$_2$Cl$_2$	L6	Toluene	N.D.
5	Ni(PPh$_3$)$_2$Cl$_2$	L7–8	Toluene	Trace
6	NiCl$_2$·dppe	L5	Toluene	38%
7	NiCl$_2$·dppe	L5	Xylene	35%
8	NiCl$_2$·dppe	L5	DCE	35%
9	NiCl$_2$·dppe	L5	THF	N.D.
10	NiCl$_2$·dppe	L5	1,4-Dioxane	46%
11[b]	NiCl$_2$·dppe	L5	1,4-Dioxane	52%
12[b]	Ni(COD)$_2$	L5	1,4-Dioxane	51%

Table 1 (Contd.)

Entry	Ni-catalyst	Ligand	Solvent	Yield of 4
13[b]	NiBr$_2$·DME	L5	1,4-Dioxane	62%
14[b]	NiBr$_2$·diglyme	L5	1,4-Dioxane	45%
15[b,c]	NiBr$_2$·DME	L5	1,4-Dioxane	69%
16[b,c,d]	NiBr$_2$·DME	L5	1,4-Dioxane	82%/73%[e]

[a] Reaction conditions: 1,3-enyne (0.1 mmol), arylboronic acids (0.2 mmol), sulfonyl chlorides (0.2 mmol), Ni-catalyst (10 mol%), ligand (10 mol%), base (0.3 mmol) and solvent (1.0 mL), Ar, 80 °C, 24 h. Yield was determined by ^{1}H NMR with CH$_2$Br$_2$ as internal standard. [b] Arylboronic acids (0.25 mmol), sulfonyl chlorides (0.25 mmol). [c] Ni-catalyst (12 mol%), ligand (12 mol%). [d] Solvent (0.5 mL). [e] Isolated yield. N.D. = desired product not detected.

enynes utilizing sulfonyl chlorides as sulfonyl source and aryl-boronic acids as nucleophile within the same nickel-catalyzed mild conditions, affording the desired sulfonylarylated allenes and dienes respectively (Fig. 1d).

Results and discussion

To commence our investigation, the easily prepared 1,3-enyne **1a** was employed as the template substrate, which reacted with

p-toluenesulfonyl chloride **2a** and phenyl boronic acid **3a** in the presence of commercially available Ni-catalyst, ligand and base at oil bath (Table 1). Initially, a series of bipyridine-based ligands were tested in this preliminary catalytic system using the $Ni(PPh_3)_2Cl_2$ as the catalyst and the K_3PO_4 as the base in toluene at 80 °C for 24 h (entries 1–5). Of particular note, goal product **4** was obtained with a yield of 25% when bidentate ligand **L5** was chosen (entry 3). To further improve the yield, several organic solvents were also tested, and the 1,4-dioxane
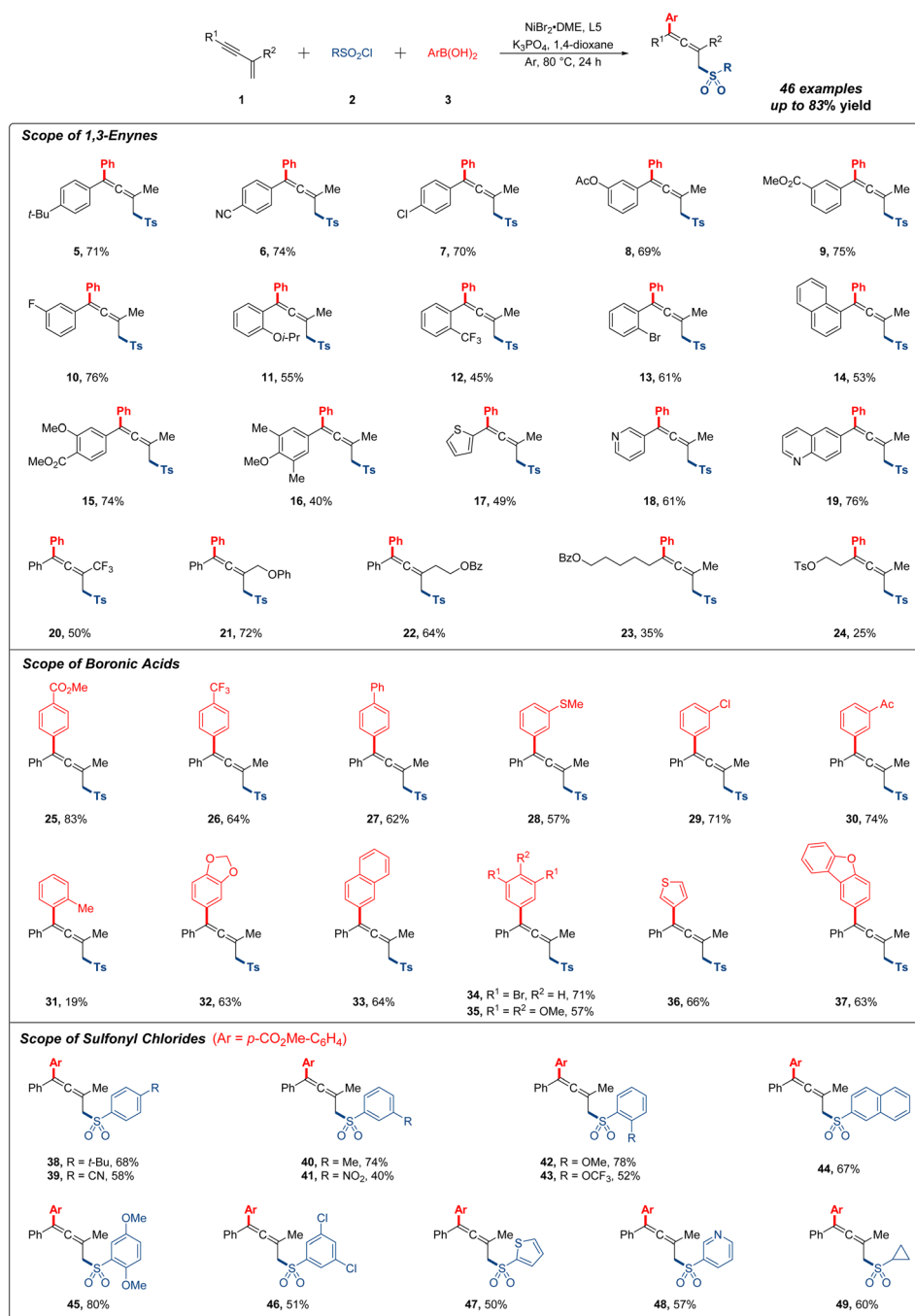

Fig. 2 Scope of 1,3-enynes, boronic acids and sulfonyl chlorides. Reaction conditions: 1,3-enynes (0.1 mmol), arylboronic acids (0.25 mmol), sulfonyl chlorides (0.25 mmol), NiBr$_2$·DME (12 mol%), 5,5′-bis(trifluoromethyl)-2,2′-bipyridine (12 mol%), K$_3$PO$_4$ (0.3 mmol) and 1,4-dioxane (0.5 mL), Ar, 80 °C, 24 h, isolated yield.

was proved to be the most suitable one (entries 6–10). Afterwards screening of different nickel catalysts showed that the NiBr$_2$·DME was also indispensable in promoting reaction efficiency, which was superior to other Ni-catalysts examined (entries 12–14). To our delight, a slight increase in reaction outcome was detected respectively when the ratio of **1a/2a/3a** was changed to 1 : 2.5 : 2.5, and the levels of Ni-catalyst and bipyridine-based ligand were all added to 12% (entries 11 and 15). Most notably, the yield of **4** was improved to 82% when the solvent concentration was 0.2 mol L^{-1} (entry 16). Furthermore, it was found that the K$_3$PO$_4$ has always been the best base compared with other bases. Finally, the reaction temperature was also briefly evaluated. Either lower or higher temperature decreased the yields to some extent. Control reactions revealed that the catalyst, ligand and base played a crucial role in this reaction (see ESI† for more detailed conditions exploring).

Having determined the optimal reaction conditions, we first explored the substrate scope of different 1,3-enynes for the 1,4-addition research. As shown in Fig. 2, the 1,4-sulfonylarylation occurred smoothly with a variety of aryl-substituted 1,3-enynes under standard conditions. Notably, substrates bearing electron-donating groups (*t*-Bu, OAc and O*i*-Pr) or electron-withdrawing groups (CN, CO$_2$Me and CF$_3$) were compatible with this reaction, affording moderate to good yields of the expected products (**5–12**). Various halogen atoms (F, Cl and Br) at the *ortho*, *meta* or *para* position of the phenyl ring were all tolerated with this procedure in generally decent yields (**7**, **10** and **13**). Multisubstituted 1,3-enynes featuring different functional groups gave the desired product in 74%, 40% and 53% yields, respectively (**14–16**). Then, a sequence of heterocyclic substrates, such as thiophene, pyridine and quinoline, were viable with the protocol to produce corresponding products (**17–19**), and target products were also detected with acceptable yields when R^2 was altered to trifluoromethyl or other long-chain alkyl in substrates (**20–22**). Regretfully, alkyl-substituted 1,3-enynes were subjected for further testing, and the yields all decreased dramatically, which were more residual in system (**23** and **24**). Of note, about 10% direct sulfonylarylation side product from the competitive reaction could be observed for most of the low yield examples.

Next, we turned our attention to the research on generality of organoboronic acids (Fig. 2). It was found that readily accessible arylboronic acids possessing all kinds of useful functional groups (CO$_2$Me, CF$_3$, Ph, SMe, Cl, and Ac) at the *meta* or *para* position of the phenyl ring were all applicable in this transformation, providing the target products in excellent yields (**25–30**). However, when arylboronic acid bearing a methyl at the *ortho*-position was used, the yield of 1,4-sulfonylarylation was only 19% probably due to the steric hindrance effect (**31**). In the case of this reaction, the substrate **1a** was recovered in 65% yield, and no other side products were monitored. Additionally, multisubstituted arylboronic acids also participated in this system with satisfactory yields (**32–35**), and the heteroarylboronic acids containing thiophene and dibenzofuran could be well applied in this reaction, giving the allenyl sulfones in 66% and 63% yields, independently (**36** and **37**).

Subsequently, we moved on to investigate the effect of sulfonyl chlorides (Fig. 2). A range of arylsulfonyl chlorides with different substituent groups (*t*-Bu, CN, Me, OMe and OCF$_3$) were all accommodated with this procedure delivering moderate to good reaction outcomes (**38–43**). Generally, electron-rich arylsulfonyl chlorides gave better yields than the electron-deficient ones. It was worth mentioning that utilizing arylsulfonyl chloride bearing a nitryl at the *meta*-position, expected product was observed in 40% yield (**41**). The employment of disubstituted arylsulfonyl chlorides and heteroarylsulfonyl chlorides were also compatible with current conditions in generally satisfied yields (**44–48**). Of particular note, cyclopropane sulfonyl chloride could also be well exploited in this reaction (**49**).

During our study, we surprisingly observed an unexpected reactivity with commercially available 2-methylbut-1-en-3-yne as the model substrate. Interestingly, this 1,3-enyne substrate unpredictably underwent 3,4-sulfonylarylation process instead of 1,4-sulfonylarylation under the same catalytic system, resulting in the formation of sulfonylarylated 1,3-diene. After screening the several bipyridine-based ligands (see ESI†), we further verified the possibility of 3,4-addition research (Fig. 3). A few terminal 1,3-enynes were briefly examined to generate corresponding products in 39–51% yields (**50–52**). Unambiguous proof of the structure of **50** was achieved by single-crystal X-ray analysis. Conspicuously, expected product was generated into
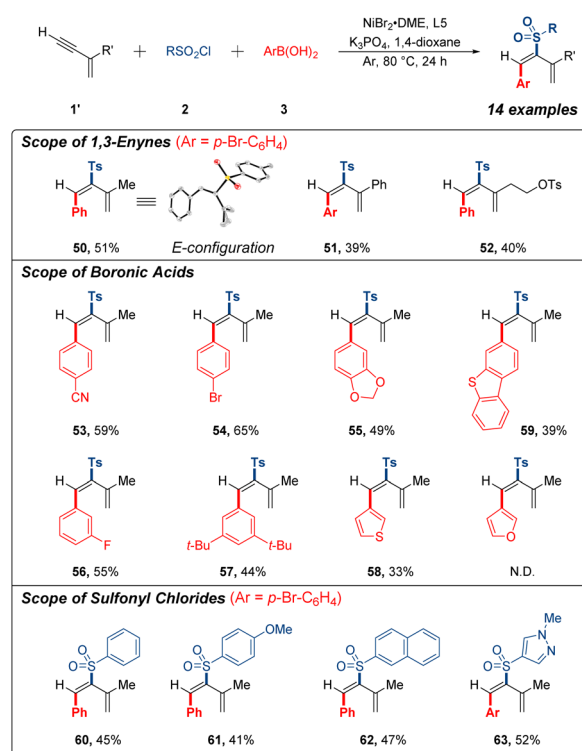

Fig. 3 Scope of 1,3-enynes, boronic acids and sulfonyl chlorides. Reaction conditions: 1,3-enynes (0.1 mmol), arylboronic acids (0.25 mmol), sulfonyl chlorides (0.25 mmol), NiBr$_2$·DME (12 mol%), 5,5′-bis(trifluoromethyl)-2,2′-bipyridine (12 mol%), K$_3$PO$_4$ (0.3 mmol) and 1,4-dioxane (0.5 mL), Ar, 80 °C, 24 h, isolated yield. N.D. = desired product not detected.
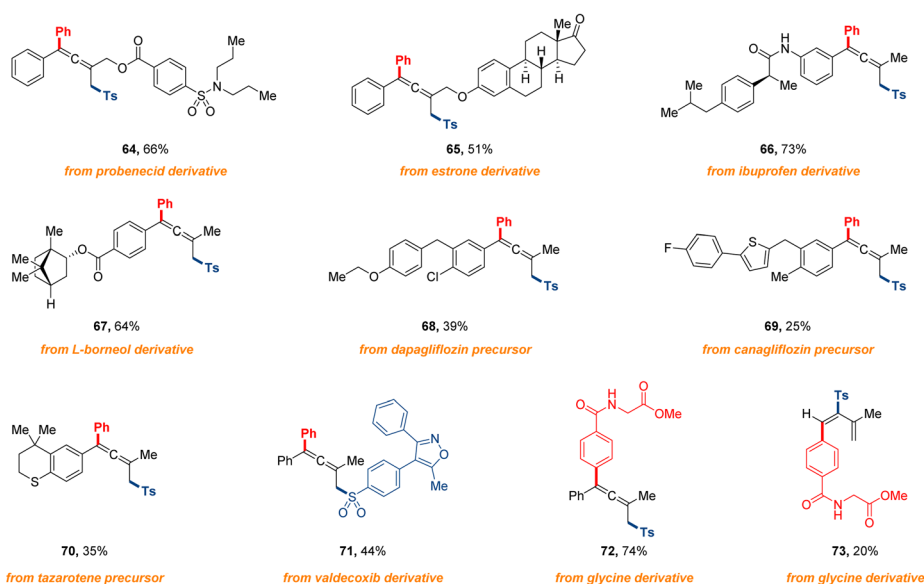
the *E* configuration. In addition, a series of arylboronic acids and sulfonyl chlorides were tested under current conditions with generally acceptable yields (**53–63**). It should be mentioned that 1,4-addition products were not detected for these substrates, and 3,4-sulfonylarylation was less effective than 1,4-sulfonylarylation as a result of the effumability and instability of these terminal 1,3-enynes in system.
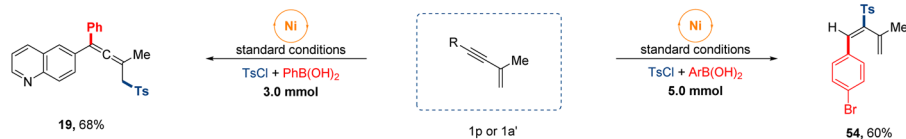
To further demonstrate the comprehensive versatility of this procedure, a series of extended experiments were conducted as depicted in Fig. 4. First of all, late-stage functionalization of bioactive natural products and pharmaceutical drugs proceeded easily. Gratifyingly, a number of structurally complex 1,3-enyne substrates derived from (pre)drug compounds and natural products, such as probenecid, ibuprofen, estrone, L-borneol and the precursor of canagliflozin, dapagliflozin and tazarotene, and the sulfonyl chloride modified from valdecoxib,

were employed as the reaction partners, which successfully underwent the 1,4-sulfonylarylation cross-coupling process to furnish the highly functionalized allenyl sulfones in 25–73% yields (**64–71**). Beyond that, we also examined the feasibility of regiodivergent sulfonylarylation of 1,3-enynes with the arylboronic acid that was derivatized from glycine, leading to the corresponding products in 74% and 20% yields, separately (**72** and **73**). The successful applications of this facile approach to these molecules will have significant implications for synthesizing complex sulfone-containing compounds. Next, two gram-scale syntheses were executed effortlessly on 3.0 mmol and 5.0 mmol scale without much decrease in the product yield. The post-transformations of sulfonylarylated allene and diene were also briefly carried out to produce corresponding products in high yields (**74** and **75**). Finally, the interesting protocol could extend to arylsulfonylalkylation with other radical precursor in
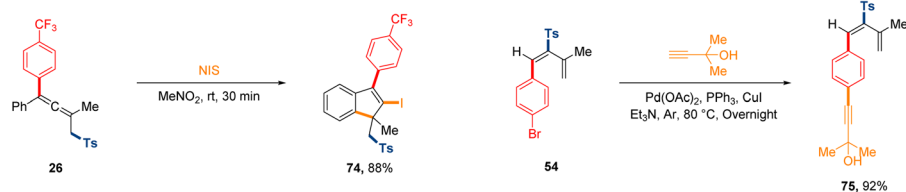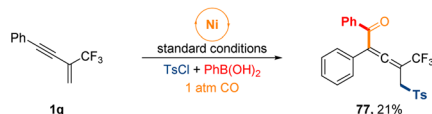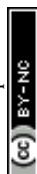

Fig. 4 Synthetic utilizations.

46% yield (**76**), and the four-component 1,4-sulfonylacylation of CF$_3$-containing 1,3-enyne also occurred in 21% yield under 1 atm CO gas (**77**).

Preliminary studies were conducted to provide some insight into the mechanism of the reaction (Fig. 5). Initially, we set out to conduct radical inhibition experiments using radical scavengers. The addition of either 1,1-diphenyl ethylene or 2,2,6,6-tetramethylpiperidinooxy (TEMPO) under standard conditions significantly suppressed this sulfonylarylation process and product (**78**) was isolated in 30% yield fortunately. When the transformation was performed under air atmosphere, no target product was observed. These observations suggested that a sulfonyl radical might be involved along the reaction course. Furthermore, the radical nature of the reaction was further supported by the radical clock experiment with α-cyclopropyl styrene affording the formation of cyclized product (**79**) through sequential ring-opening of the cyclopropylmethyl radical intermediate and intramolecular cyclization, while the ring-opened sulfonylarylated product was not detected. On the other hand, the reaction was performed with a catalytic amount of phenyl boronic acid, giving the trace allenyl sulfones. While none of propargyl chloride or allenyl chloride was monitored in system. Besides, in order to eliminate the influence of light-mediated pathway of radical generation, the reactions were conducted in the dark under standard conditions, and the isolated yields were almost unchanged whether 1,4-sulfonylarylation or 3,4-sulfonylarylation. Finally, no expected products were observed

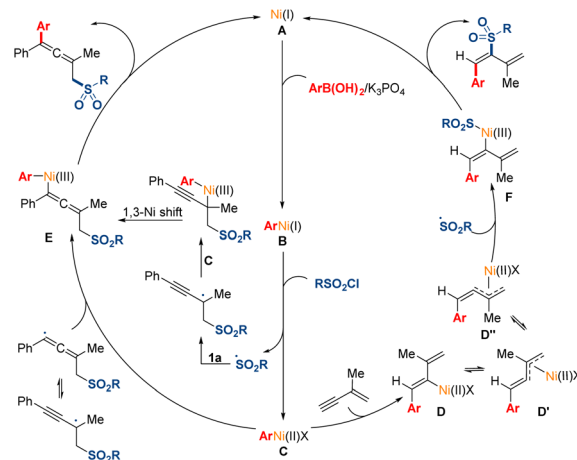

Fig. 5 Mechanistic studies.

Fig. 6 Proposed mechanism.

when other terminal alkynes substrates were tested under our conditions, which might indicate the formation of intermediate π-allylnickel species in our catalytic system.

A mechanistic scenario is proposed for this transformation based on the above experimental studies and pervious literature reports (Fig. 6).[5,12,16] Initially, the transmetalation of the Ni(I) species (**A**), which might be generated by *in situ* reduction from Ni(II), with arylboronic acid would deliver the Ni(I) species (**B**). Then, the Ni(I) species (**B**) could react with sulfonyl chloride through a single electron transfer pathway, leading to the generation of the Ni(II) species (**C**) and the corresponding radical. Subsequently, the sulfonyl radical might add to the double bond in 1,3-enyne **1a** to afford a propargyl radical, and the tautomerized allenyl radical might be direct trapped by the Ni(II) species (**C**). Moreover, this pathway of 1,3-Ni shift process could not be excluded. When terminal 1,3-enyne **1a′** was used, the Ni(II) species (**C**) might preferentially undergo migratory insertion into the less substituted terminal triple bond in the substrates probably due to the steric hindrance effect. The intermediate Ni(II) species (**D**) might undergo isomerization to generate the π-allylnickel(II) species (**D′**). Then, the sulfonyl radical might be trapped by the Ni(II) species (**D″**), which might undergo π-allylnickel-assisted *syn*/*anti* isomerization from the Ni(II) species (**D′**). Finally, the reductive elimination of the produced intermediate Ni(III) species (**E** and **F**) could release the desired products and regenerate the Ni(I) species (**A**) for the next catalytic cycle.

Conclusions

In summary, a novel methodology for nickel-catalyzed substrate-controlled regiodivergent sulfonylarylation of 1,3-enynes is presented. The versatile protocol rapidly delivers the selective construction of valuable sulfonylarylated allenes or dienes from fine-tuned 1,3-enynes with wide substrate scope and acceptable functional group tolerance under the same catalytic system. Preliminary control experiments provide evidence supporting the involvement of sulfonyl radicals. This
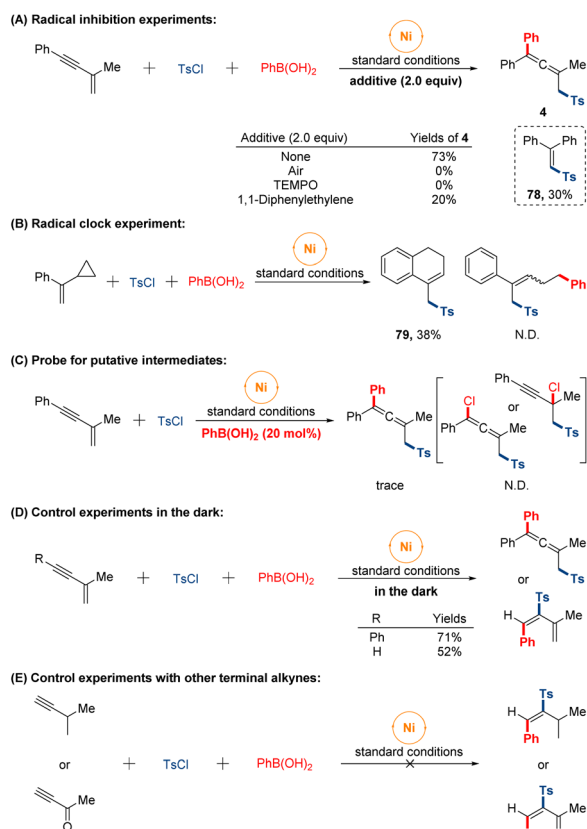
facile approach also provides a valuable strategy for the late-stage modification of complex sulfone-containing molecules.

Data availability

Author contributions

Z. Chi performed the experiments and wrote the manuscript and ESI. Y. Zhou and B. Liu prepared some of the substrates and checked the ESI. X. Xu and X. Liu checked the manuscript. Y. Liang directed the project.

Conflicts of interest

There are no conflicts to declare.

Acknowledgements

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